

Att. Docket No. 10191/1629

## <u>D STATES PATENT AND TRADEMARK OFFICE</u>

Appl. Serial No.

09/720,761

Confirmation No. 5642

Title

METHOD OF PLASMA

ETCHING OF SILICON

Applicant(s)

Franz LAERMER et al.

Filed

March 26, 2001

TC/A.U.

1765

Examiner

Kin Chan Chen

Docket No.

10191/1629

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail

in an envelope addressed to:

Customer No.

26646

Mail Stop

Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450

MAIL STOP AF

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Signature: AARON'E. DED

(33,865)

## **TRANSMITTAL**

SIR:

Transmitted herewith for filing in the above-identified patent application is an Amendment After A Final Office Action.

This is also a Petition under 37 C.F.R. § 1.136(a) to extend the three-months response date by two months from September 7, 2004 to November 7, 2004.

The Commissioner is authorized to charge the appropriate fees, which are believed to be \$430.00 for the two-months extension, to Deposit Account No. 11-0600, and is also authorized, as appropriate and/or necessary, to charge any additional fees (including any Rule 136(a) extension fees) or credit any overpayment to Deposit Account No. 17-0600. Two duplicate copies of this transmittal letter are enclosed for that purpose

Respectfully submitted,

Bv:

Richard L. Mayer

(Reg. No. 22,490)

10/19/2004 HALI11

01 FC:1252

00000074 110600

430.00 DA

09720761

One Broadway

New York, New York 10004

**KENYON & KENYON** 

(212) 425-7200

**CUSTOMER NO. 26646** 

NY01 670254 v 1